

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	0	lead adj frame same pattern\$3 same electroplat\$3 same remov\$3 same encapsulat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/01/17 10:08
S2	4	lead adj frame and pattern\$3 same electroplat\$3 same remov\$3 same encapsulat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/01/17 10:13
S3	12	semiconductor and package and pattern\$3 same electroplat\$3 same remov\$3 same encapsulat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/01/17 10:23
S4	5	first adj mask and second adj mask and pattern\$3 same electroplat\$3 same remov\$3 same encapsulat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/01/17 10:24